In the Specification:

Please amend the specification where indicated.

<u>Λt page 1, lines 5-15:</u>

At page 5, line 20 - page 6 line 13:

FIG. 1 shows a system 100 for analyzing a semiconductor die 102, according to an example embodiment of the present invention. The system includes a test head 105 adapted to hold the die 102 and to dock with a chamber 110 via a coupling arrangement 140. Once the test head is docked with the chamber, one or more perturbation devices 101, including a light source 106 and other devices, such as a FIB, laser, sonic, microwave, electron beam or ion beam device, is used to analyze the die. Operation control data, such as chamber condition, die response, and other data, is provided to a controller 115. The controller is further adapted to receive response data from the die, such as electrical data obtained from die outputs. The perturbation devices 101 are also optionally coupled to the controller 115, and the controller can be adapted to control and receive feedback from the devices 101. A monitor 120 is coupled to the controller 115 and adapted to display information such as response data, control data. In one particular implementation, the monitor is used as part of an interface for controlling the system 100. For more information regarding the use of a controller in connection with the present invention, reference may be made to U.S. Patent Application Serial No.







09/838,672 (AMDΛ.519PA/IT3991P4), entitled "Semiconductor Analysis Arrangement and Method Therefor."

At page 7, lines 6-19:

